

OK TO ENTER: /E.J./

06/03/2010

MS AF  
PATENT  
8074-1143

**IN THE U.S. PATENT AND TRADEMARK OFFICE**

In re application of

Koichi NANIWAE

Conf. 9283

Application No. 10/573,492

Group 2892

Filed May 15, 2006

Examiner E. Jones

METHOD OF CLEANING TREATMENT AND METHOD FOR MANUFACTURING  
SEMICONDUCTOR DEVICE

**SUPPLEMENTAL RESPONSE AFTER FINAL REJECTION**

Assistant Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

May 27, 2010

Sir:

This responds to the Official Action of February 19, 2010 and  
is supplemental to the response filed May 19, 2010.

**Remarks** begin on page 2 of this paper.